

EAST Search History

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	124	(gustaaf.in. near5 feltz.in.) (cheng-qun.in. near4 gui.in.) (johan.in. near4 hoefnagels.in.)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/02/14 16:32
L2	32295	((substrate wafer reticle mask) near4 (temperature heat\$3)) with (measur\$5 sens\$3 detect\$3 determin\$5)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/02/14 16:33
L3	42201	(substrate wafer reticle mask) with ((dimension\$3 near response) expan\$4 deform\$5 (spatial near distribution)) with (calculat\$3 determin\$5 predict\$3 model\$3 coefficient co\$5)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/02/14 16:34
L4	1	1 and 2.clm.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/02/14 16:34
L5	3148	2 with (area region poriton section)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/02/14 16:34
L6	217	3 and 5	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/02/14 16:34
L7	4790	2 with (area region portion section)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/02/14 16:35

L8	378	3 and 7	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/02/14 16:35
L9	189080	(different first second) near5 (area region portion section) near5 (substrate wafer mask reticle)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/02/14 16:35
L10	85	8 and 9 and @ad<="20040329"	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/02/14 16:36
L11	274779	(pattern\$3 form\$3 expos\$5 record\$3 project\$3) near5 (pattern image mark) near5 (substrate wafer mask reticle)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/02/14 16:36
L12	36	10 and 11	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/02/14 16:37
L13	22	(11 and 2 and 3).clm.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/02/14 16:37
L14	65834	(shape cross\$section\$3 size location position disposition disposed) near3 (beam light radiation illumination) with (correct\$3 adjust44 compensat\$3 chang\$3)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/02/14 16:53
L15	1	(14 and 3 and 7).clm.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/02/14 16:54
L16	22	(11 and 2 and 3).clm.	US-PGPUB; USPAT	OR	ON	2009/02/14 16:55

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